

Sheet 1 of 1

Sub Form PTO-1449

Docket Number (Optional)

Application Number

SAM-0438CIP

10/672,255

Applicant

Ki-Yeol Kim

Filing Date

09/26/03

Group Art Unit

2816 2876

INFORMATION DISCLOSURE CITATION  
IN AN APPLICATION

(Use several sheets if necessary)

## U. S. Patent Documents

EXAMINER INITIALS		DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
WLL	AA	4,206,323	06/03/80	Padgett, et al.	179	84	08/31/78
	AB	5,457,461	10/10/95	Schuermann	342	42	08/11/93
	AC	5,548,291	08/20/96	Meier et al.	342	51	06/07/95
	AD	6,617,172	09/09/03	Usami	438	2	08/31/01
	AE						
	AF						
	AG						
	AH						
	AI						
	AJ						
	AK						

## FOREIGN PATENT DOCUMENTS

		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
							YES	NO
	AL							
	AM							
	AN							
	AO							
	AP							
	AQ							

## OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

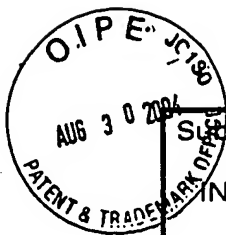
WLL	AR	International Standards Organization, ISO/IEC JTC 1/SC 17, "Identification cards-Contactless integrated circuit card(s) - Proximity cards-Part 1: Physical characteristics," October 20, 1999, pages 1-5
	AS	International Standards Organization, ISO/IEC JTC 1/SC 17, "Identification cards-Contactless integrated circuit card(s) - Proximity cards-Part 2: Radio frequency power and signal interface," July 13, 2000, pages 1-11
	AT	International Standards Organization, ISO/IEC JTC 1/SC 17, "Identification cards-Contactless integrated circuit card(s) - Proximity cards-Part 3: Initialization and anticollision," July 13, 2000, pages 1-48

EXAMINER

DATE CONSIDERED

1/13/05

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP § 609; Draw line through citation if not in conformance and not considered. Include copy with next communication to applicant.



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	AA						
	AB						
	AC						
	AD						
u	AE	3,991,265	11/09/76	Fukuda, et al.	178	5.6	05/17/74
u	AF	4,532,635	07/30/85	Mangulis	375	1	08/19/83
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	AH						
	AI						
	AJ						
	AK						

## FOREIGN PATENT DOCUMENTS

		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
							YES	NO
u	AL	JP405307369A	11/19/93	Japan	G09G003	36		
	AM							
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	AO							
	AP							
	AQ							

## OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

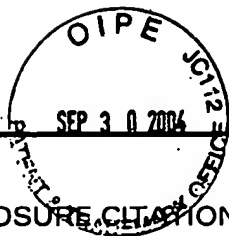
	AR	
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Group Art Unit

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EXAMINER INITIALS		DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
	AA						
	AB						
	AC						
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mm	AG	3,689,885	09/05/72	Kaplan, et al.	340	152T	09/15/70
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	AI	5,360,967	11/01/94	Perkin, et al.	235	375	08/25/93
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	AK						

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							YES	NO
	AL							
	AM							
	AN							
	AO							
	AP							
	AQ							

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